Shock wave and modelling study of the unimolecular dissociation of Si(CH₃)₂F₂: an access to spectroscopic and kinetic properties of SiF₂

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Electronic Supplementary Information

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ESI – 1 Modelling of oscillator strengths for UV absorptions of SiF_x (x = 1 – 3)

Table S1Experimental absorption cross sections of $SiF_2(\sigma, base e, in cm^2)$ attemperatures near 1600 and 3000 K (see main text).

λ / nm	σ (1600 K)/ 10 ⁻¹⁸ cm ²	σ (3000 K)/10 ⁻¹⁸ cm ²
200	1.0	-
210	4.5	-
215	19.0	19.0
222	24.5	20.5
230	15.5	16.0
235	8.4	11.0
240	3.0	-
245	1.0	-
250	0.5	-
255	0.5	-

Table S2 Wavelengths of UV- absorption maxima λ (in nm) and oscillator strengths f (determined by time-dependent density functional theory, TD-DFT, on the ω B97X-D level and with 6-311+G(3df) basis set; the calculations in **ESI** – 1 and **ESI** – 2 employed the Gaussian 09 software. revision – A.02-SMP, of ref. S1).

DFT model	λ (SiF ₃)	$f(SiF_3)$	λ (SiF ₂)	$f(SiF_2)$	λ (SiF)	f(SiF)
ωB97X-D	186	0.1259	225	0.1902	278	0.1104
	185	0.1259			218	0.0226
					195	0.0436

a. Reaction enthalpies

All calculations were performed at the CBS-QB3 and G4 ab initio composite levels with geometries and harmonic vibrational frequencies derived at the B3LYP/6-311++G(3df,3pd) DFT level.

Table S3 Dissociation enthalpies of $Si(CH_3)_2F_2$ and $Si(CH_3)F_2$ (from CBS-Q//B3LYP/6-311++G(3df,3pd) and G4//B3LYP/6-311++G(3df,3pd) calculations, enthalpies at 0 K and in kJ mol⁻¹).

Reaction	CBS-Q//B3LYP/6-	G4//B3LYP/6-
	311++G(3df,3pd)	311++G(3df,3pd)
$Si(CH_3)_2F_2 \rightarrow$	410.0	401.7
$Si(CH_3)F_2 + CH_3$		
$Si(CH_3)F_2 \rightarrow SiF_2 + CH_3$	173.2	169.9

b. Properties of the potential energy surface along the minimum-energy path(MEP) for the reaction $Si(CH_3)_2F_2 \rightarrow CH_3 + Si(CH_3)F_2$



Fig. S1 Electronic potential for the reaction $Si(CH_3)_2F_2 \rightarrow CH_3 + Si(CH_3)F_2$ along the MEP. G4//B3LYP/6-311++G(3df,3pd) calculations fitted with a Morse function with $D_e = 447.3 \text{ kJ mol}^{-1}$ and $\beta = 1.51 \text{ Å}^{-1}$



Fig. S2 Transitional modes ν of the reaction Si(CH₃)₂F₂ \rightarrow CH₃ + Si(CH₃)F₂ along the MEP, calculated at the B3LYP/6-311++G(3df,3pd) level. Exponential decay functions with decay parameters $\alpha = 1.50$ (**■**), 0.43 (o), 0.48 (•), 0.40 (Δ) and 0.43 Å⁻¹ (**▲**).



Fig. S3 Rotational constants of Si(CH₃)₂F₂ calculated along the MEP for the reaction Si(CH₃)₂F₂ \rightarrow CH₃ + Si(CH₃)F₂, calculated at the B3LYP/6-311++G(3df,3pd) level (fit with a function (B+C)/2 = 0.113 cm⁻¹/[1 + 0.330 (r -1.849) + 0.103 (r - 1.849)²].

c. Modelling of limiting high pressure rate constants

Table S4 Modelled limiting rate high pressure constants for the recombination reaction $CH_3 + (CH_3)SiF_2 \rightarrow (CH_3)_2SiF_2$ ($k_{rec,\infty}$, in cm³ mol⁻¹ s⁻¹) and the reverse dissociation reaction $Si(CH_3)_2F_2 \rightarrow CH_3 + Si(CH_3)F_2$ (k_{∞} , in s⁻¹) (calculations with the simplified statistical adiabatic channel/classical trajectory model, SACM/CT, of ref. S2 and S3, employing the parameters of Figs. S1 - S3, PST = phase space theory, rigidity factors $f_{rigid} = k_{rec,\infty} / k_{rec,\infty}^{PST}$, equilibrium constants $K_c = k_{\infty} / k_{rec,\infty}$, in mol cm⁻³).

T/K	$k_{\rm rec,\infty}^{\rm PST}$	$f_{ m rigid}$	k _{rec,∞}	K _c	k _∞
1500	3.65x10 ¹⁴	5.05x10 ⁻²	1.84x10 ¹³	5.62x10 ⁻¹¹	1.03x10 ³
1750	3.84x10 ¹⁴	5.13x10 ⁻²	1.97×10^{13}	4.91x10 ⁻⁹	9.66x10 ⁴
2000	3.98x10 ¹⁴	5.20x10 ⁻²	2.07×10^{13}	1.25x10 ⁻⁷	2.58×10^{6}
2500	4.21x10 ¹⁴	5.30x10 ⁻²	2.23x10 ¹³	9.04x10 ⁻⁶	2.02×10^8

 $k_{\infty} = 1.24 \text{ x } 10^{19} (T/2000 \text{ K})^{-6.63} \exp(-58400 \text{ K}/T) \text{ s}^{-1}$

d. Modelling of limiting low pressure rate constants

Table S5 Modelled limiting low pressure rate coefficients (k_0 , in cm³ mol⁻¹ s⁻¹) for the reaction Si(CH₃)₂F₂ (+ Ar) \rightarrow CH₃ + Si(CH₃)F₂ (+ Ar) (strong collision rate coefficients k_0^{SC} , calculated following ref. S4 and employing the parameters of Figs. S1 – S3; weak collision efficiencies $\beta_c = k_0 / k_0^{SC}$, as following from the master-equation treatment of ref. S5, were determined with assumed standard values of average energies transferred per collision of $<\Delta E> = -100/hc \text{ cm}^{-1}$).

T/K	$k_0^{ m SC}$	$\beta_{\rm c}$	k_0
1500	1.18x10 ¹²	0.038	4.49×10^{10}
1750	1.24×10^{13}	0.028	3.46x10 ¹¹
2000	4.88x10 ¹³	0.021	1.02×10^{12}
2500	1.71×10^{14}	0.011	1.89x10 ¹²

 $k_0 = [\text{Ar}] 2.94 \text{ x } 10^{25} (T/2000 \text{ K})^{-25.04} \exp(-61980 \text{ K}/T) \text{ cm}^3 \text{ mol}^{-1} \text{ s}^{-1}$

e. Modelling of falloff curves

Falloff curves for the reaction Si(CH₃)₂F₂ (+ Ar) \rightarrow CH₃ + Si(CH₃)F₂ (+ Ar) were represented in the representation proposed in ref. S6 – S8 (see main text), employing center broadening factors F_{cent} estimated according to ref. S8 and leading to values of F_{cent} = 0.039 (1500 K), 0.045 (1750 K), 0.051 (2000 K) and 0.073 (2500 K).



Fig. S4 Modelled falloff curves for $Si(CH_3)_2F_2$ (+ Ar) \rightarrow CH₃ + Si(CH₃)F₂ (+ Ar). Calculations for 1500, 1750, 2000 and 2500 K (from bottom to top).

f. Molecular parameters

Bond dissociation enthalpy for Si(CH₃)₂F₂ \rightarrow CH₃ + Si(CH₃)F₂ at 0 K: Δ H₀⁰ = 401.7 kJ mol⁻¹ (from G4//B3LYP/6-11++G(3df,3pd) calculations).

Si(CH₃)₂F₂ vibrational frequencies: 141, 153, 193, 210, 250, 320, 322, 635, 707, 758, 789, 801, 828, 905, 930, 1307, 1309, 1453, 1455, 1462, 1465, 3034, 3036, 3106, 3109, 3111, 3111 cm⁻¹ (from B3LYP/6-311++G(3df,3pd) calculations).

Si(CH₃)₂F₂ rotational constants: A = 0.126, B = 0.114, C = 0.112 cm⁻¹ (σ = 2) (from B3LYP/6-311++G(3df,3pd) calculations).

Si(CH₃)F₂ vibrational frequencies: 130, 213, 271, 324, 635, 774, 778, 846, 897, 1270, 1441, 1454, 3029, 3112, 3131 cm⁻¹ (from B3LYP/6-311++G(3df,3pd) calculations).

Si(CH₃)F₂ rotational constants: A = 0.231, B = 208, C = 0.123 cm⁻¹ (σ = 1) (from B3LYP/6-311++G(3df,3pd) calculations).

CH₃ vibrational frequencies: 541, 1407, 1407, 3111, 3289, 3289 cm⁻¹ (from B3LYP/6-311++G(3df,3pd) calculations).

CH₃ rotational constants: A = 9.601, B = 9.601, C = 4.800 cm⁻¹ (σ = 3) (from B3LYP/6-311++G(3df,3pd) calculations).

Lennard-Jones parameters: $\sigma(Si(CH_3)_2F_2) \approx \sigma(SiF_4) = 4.88$ Å and $\epsilon/k(Si(CH_3)_2F_2) \approx \epsilon/k(SiF_4) = 171.9$ K (from ref. S9); $\sigma(Ar) = 3.47$ Å, $\epsilon/k(Ar) = 114$ K (from ref. S10).

g. References

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